

# As grown ultra-thin MgB<sub>2</sub> films for superconducting detectors

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**Abstract**—For both hot-electron bolometers (HEBs) and superconducting single-photon detectors (SNSPDs) high quality thin superconducting films are of crucial importance. Using MgB<sub>2</sub> with a critical temperature ( $T_c$ ) of 39K (vs 15-16K for NbN) much higher operation temperatures (15-30K) could be achieved. In this case compact cryocoolers could be used, hence extending missions life time significantly. Furthermore, utilization of MgB<sub>2</sub> for HEB mixer improves gain and noise bandwidths due to shorter electron-phonon interaction time and better acoustic matching to the substrate. Unfortunately, reduction of film thickness is usually followed by reduction of  $T_c$  (in 3-5nm NbN films  $T_c$  is 9-11K), while for HEBs and SNSPDs a combination of both a small thickness and a high  $T_c$  is desirable. Low film roughness and high homogeneity are other importance merits. A hybrid physical chemical vapour deposition (HPCVD) method has been reported to be much more efficient for high quality thin MgB<sub>2</sub> film depositions compared to e.g. molecular beam epitaxy (MBE), co-evaporation etc. It has been shown before than a gain bandwidth (GBW) of 6GHz can be achieved for HEBs made from 15-20nm MgB<sub>2</sub> films. Our goal is to develop a deposition method providing MgB<sub>2</sub> films thinner than 10nm and with a  $T_c > 30K$  in order to extend GBW to  $> 10GHz$ .

Here we present our recent results on ultra-thin MgB<sub>2</sub> film deposition using our (in-house built) HPCVD system. To study film properties on submicron level films were patterned in bridges with dimensions varying from  $0.3 \times 0.3 \mu m^2$  to  $1 \times 1 \mu m^2$ . 20nm thick films had a room temperature resistivity  $\rho_{295K}$  of  $50 \mu\Omega \cdot cm$  ( $13 \mu\Omega \cdot cm$  for un-patterned films) with a  $T_c$  of 39K and a critical current density  $J_c$  (4.2K) up to  $1.2 \times 10^8 A/cm^2$ . A deposition rate of  $0.8 \text{ \AA}/s$  is much lower compared to previously reported values (vs  $3 \text{ \AA}/s$ ). We obtained MgB<sub>2</sub> films as thin as 5-7nm with a  $T_c$  of 31-34K, a  $\rho_{295K}$  (in sub-micron scale bridges) of  $\sim 100 \mu\Omega \cdot cm$ , and a  $J_c$  of  $(1-3) \times 10^7 A/cm^2$ . Using such films antenna integrated HEB mixers ( $1 \times 1 \mu m^2$ ) have been fabricated which showed both a low noise and a noise bandwidth  $> 10GHz$  (see also “MgB<sub>2</sub> HEB mixer with an 11GHz bandwidth” on this conference).